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PATENT
8097-1003

IN THE U.S. PATENT AND TRADEMARK OFFICE

In re application of

Takahuki SHIMAMUNE et al.

Conf. 2298

Application No. 10/527,801

Group 2892

Filed October 11, 2005

Examiner E. Ullah

PROCESS FOR PRODUCING HIGH-PURITY SILICON
AND APPARATUS

AMENDMENT

Assistant Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

April 1, 2008

Sir:

In response to the Official Action mailed March 3, 2008, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 17 of this paper.